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Defect enhances photocatalytic activity of ultrathin TiO\textsubscript{2} (B) nanosheets for hydrogen production by plasma engraving method

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Graphical Abstract

Highlights

\begin{itemize}
  \item Plasma treatment was used to prepare defects on surface and bulk of TiO\textsubscript{2} (B).
  \item Formation of defects can narrow the band gap of TiO\textsubscript{2} (B).
  \item Plasma treatment of TiO\textsubscript{2} (B) induces defects of O vacancy and Ti\textsuperscript{3+}.
  \item TiO\textsubscript{2} (B) nanosheets with defects enhanced photocatalytic production of H\textsubscript{2}.
\end{itemize}
Abstract

As for practical application, ultrathin two-dimension (2D) materials have exhibited high performances in photocatalysis, electrocatalysis, and supercapacitors. Usually, when used 2D TiO$_2$ (B) nanosheet as a photocatalyst, it absorbs only ultraviolet light, and several approaches have been taken to narrow the band gap of TiO$_2$. Thus, we demonstrated a facile and environmental friendly method to enhancing hydrogen production by introducing defects of O vacancy and Ti$^{3+}$ in surface and bulk TiO$_2$ (B) nanosheets through the ambient-temperature plasma engraving treatment. After plasma treatment, the band gap of the 2D TiO$_2$ (B) nanosheets decreased from approximately 3.13 eV to 2.88 eV and the H$_2$ evolution performance of them is almost twice as high as pristine TiO$_2$ (B) nanosheets under AM 1.5 illumination. The enhanced photocatalytic performances arise from the doping defect of O vacancy and Ti$^{3+}$, narrowing the energy band gap and increasing more active sites of material surface with function of plasma engraving. The findings in this work may provide a new approach for improving the photocatalytic activities of other metal oxides.

Key words: TiO$_2$ (B) nanosheets; Plasma treatment; Oxygen vacancies; Photocatalytic activity.

1. Introduction

Photocatalytic overall water splitting for hydrogen generation is one of the most promising ways for supplying clean and sustainable energy [1-3]. Currently, the most
effective photocatalytic catalysts are based on oxides such as TiO$_2$, WO$_3$ and Fe$_2$O$_3$ [4, 5], and sulfides such as MoS$_2$ and CdS [6, 7]. Moreover, constructing unique nanostructures of the catalysts, such as 3D nanoparticles and 1D nanorods with well-defined facets[8, 9], has been successfully used to promote efficient interfacial charge transfer and facilitate photocatalytic reaction at the photocatalyst/electrolyte interfaces [10, 11]. Among various nanostructures, ultrathin two-dimensional (2D) nanocrystals have attracted tremendous attention owing to their unique properties, arising from their large surface area and confined thickness in atomic scale [12].

TiO$_2$ (B) with 2D structure was firstly obtained as a promising semiconductor for hydrogen production because of its high chemical stability, environmental benignity, and low cost [13]. However, the high overpotential for hydrogen generation and inability to absorb visible light limited further applications of TiO$_2$ (B) nanosheets. In order to solve these issues, many kinds of methods had been put forward to modify the TiO$_2$ (B) nanosheets, including metal and nonmetal doping [14-16]. Through doping, the solar absorption performance of TiO$_2$ has been improved [9, 17]. On the other hand, the drawback of these approaches is that the dopants always become the charge carrier recombination centers, which would restrain photocatalytic activity. Therefore, developing TiO$_2$ (B) photocatalyst with both abundant active sites and good crystallinity is an efficient way to simultaneously achieve high hydrogen generation performance and long-term stability. Many effective engineering approaches were applied to prepare defected TiO$_2$, including chemical reaction driven, thermal treatment (hydrogen or oxygen depleted) and high energy particle
Among them, the plasma treatment could create defects on TiO₂ surfaces conveniently and environmentally friendly. According to previous reports, only the surface layer of the TiO₂ nanowires was modified by plasma treatment, but with no further deterioration in the bulk materials [13]. While it also could protect structural integrity of original material, the plasma engraving technology significantly increases the high energy surface area and generates vacancy defects, particularly for ultrathin layer material of TiO₂ (B) nanosheets [20, 21]. Thus, engineering defect structure on the basal TiO₂ (B) nanosheets can be expected to increase the exposure of active sites and, furthermore, dramatically improve the hydrogen generation performance.

Herein, we highlight a scalable pathway to introduce the engineering defects to TiO₂ (B) nanosheets. This 2D ultrathin structure of TiO₂ (B) has more advantage than other bulk structure of nanowires and nanoparticles under the plasma treatment. More oxygen vacancies could be easily engraved, and surface area could be easily increased for the 2D ultrathin structure of TiO₂ (B). TiO₂ (B) nanosheets with more defects O vacancy and Ti⁴⁺ exhibits better photocatalytic performance than pristine TiO₂ (B) nanosheets in the production of H₂ under full spectrum light. This approach of plasma treatment is expected to be applied to other ultrathin 2D materials.

2. Experimental procedure

2.1 Synthesis of TiO₂ (B) material.

Ultrathin TiO₂ (B) nanosheets were prepared by a further modified synthetic method reported by Wang et al [22]. In a typical synthesis of ultrathin TiO₂ (B)
nanosheets, 0.5 mL TiCl$_4$ (Alfa Aesar, 99.6%) reacted with 15 mL EG (Ethylene glycol, Alfa Aesar, 99%) till no HCl gas was formed in a beaker at room temperature. Then 0.5 mL water was introduced into the mixtures and they were transferred into a 20 mL Teflon-lined stainless-steel autoclave. The sealed autoclave was heated for 4 h at 150 °C. The as-formed white products were collected via centrifugation and washed by water and ethanol. Finally, the products were dried in vacuum oven for 24 h at 60 °C.

2.2 Plasma engraving of TiO$_2$ (B) nanosheets.

The plasma engraving of TiO$_2$ (B) nanosheets was carried out in a plasma cleaner apparatus (Harrick Plasma, 13.56 MHz/18W RF source) under argon atmosphere. The pressure of chamber and engraving time were 40 Pa and 2 hours, respectively. Schematic representation of the synthesis procedures of plasma engraving treatment was shown in Scheme 1.

2.3 Characterization.

The crystal structure of the TiO$_2$ (B) was investigated through an X-ray diffraction (XRD, Bruker D8 Advance) by using Cu K$_\alpha$ radiation. The Brunauer-Emmett-Teller (BET) surface areas were examined by a surface area analyzer (BEL Sorp-II mini) with nitrogen absorption at 77 K. Morphologies and microstructure were determined by transmission electron microscopy (TEM, JEOL-2100), high-resolution TEM (HRTEM) coupled with selective-area electron diffraction (SAED). The thickness was tested by Atomicforce microscopy (AFM, SPA-300HV). UV-vis diffuse reflectance absorption spectra (DRS) were recorded by
a UV-vis spectrophotometer (UV-2700, Shimadzu). Raman spectra were identified by using a Thermo-scientific DXR spectrometer in the range of 100-1000 cm\(^{-1}\) at 532 nm. The Fourier-transformed infrared spectra (FTIR) were collected using a Thermo-scientific iS10 FT-IR spectrometer. X-ray photoelectron spectroscopy (XPS, PHI5000 Versa Probe) of the plasma treatment sample was performed by using Al \(K\alpha\) radiation (1486.7 eV). All the binding energies were calibrated using the C 1s peak (BE = 284.8 eV) as standard. The electron paramagnetic resonance (EPR) spectra were measured using JEOL JES-FA200 EPR spectrometer at 77 K. For EPR tests, the samples were dispersed in purified methanol with 5, 5-dimethyl-1pyrroline-N-oxide (DMPO) as trapper.

2.4 Evaluation of photocatalytic activity.

The photocatalytic evaluations of \(\text{H}_2\) evolution were carried out in a closed gas circulation system with an external-irradiation type of a glass reactor. The light source was a 300 W Xenon arc lamp with an AM 1.5 filter (Oriel, USA) as simulated sunlight source. The as-formed gas was analyzed using an online gas chromatograph (GC-8A; Shimadzu) equipped with a thermal conductivity detector (TCD).

Photoelectrochemical measurements were investigated by using an electrochemical workstation (Gamry Interface 1000) with standard three-electrode system: the obtained \(\text{TiO}_2\) samples as work electrode, an Ag/AgCl as reference electrode, and platinum foil as opposite electrode. The electrolyte was 0.1 M \(\text{Na}_2\text{SO}_4\) aqueous solution. For the preparation of the photoelectrode, 12.5 mg of sample was dissolved in 1 mL of alcohol and 0.01 mL naphthol solution under magnetic stirring.
The mixtures were dip-coated onto a 1 × 1 cm² FTO glass electrode to form a film and then dried at room temperature to ensure good electrical contact.

3. Results and discussions

Crystal structures and crystalline phases of the different samples in this study are significant for the following photocatalytic performances. Fig. 1(a) shows the XRD patterns of the pristine and plasma treated TiO₂ (B) samples. There is no obvious difference between these two samples. The diffraction peaks at 25.05°, 28.61°, 43.48° and 48.63° can be assigned to (110), (002), (003) and (020) crystal planes of TiO₂ (B) phase, respectively. Fig. 1(b) shows the N₂ adsorption isotherms. The BET specific surface area of plasma treated TiO₂ (B) (515 m²/g) is higher than that of pristine TiO₂ (B) (305 m²/g). Contrast the relative location of pore peak about the red line in Fig. S1, the mesoporous size of plasma treated TiO₂ (B) (3-6 nm) has smaller than that pristine TiO₂ (B) (4-6 nm). It is because of the plasma engraving effect, causing the destruction of the surface layer structure. The pristine TiO₂ (B) nanosheets exhibit a flat-whiskered morphology with a mean length of about 100 nm and width of 20-40 nm, as shown in Fig. 1(c). The single layer thickness of TiO₂ (B) nanosheet is about 0.79 nm, which is determined by AFM (Fig. S2). The uniform lattice fringes could be observed over a wide region, as shown in Fig. 1(d). The (110), (003), (020) and (003) facets were decided by the interplanar spacing. The angles, between (110) and (003) facets and (020) and (003) facets, are 84.7° and 90° respectively, which match with results of lattice parameters about the monoclinic phase. The SAED result is shown in inset Fig. 1(d). The diffraction rings of (110), (003) and (202) can be observed clearly. After plasma treatment, localized area of the sample is destructed and the surface
becomes bumpy and discontinuous, as marked by white arrows in Fig. 1(e). The TiO$_2$ (B) nanosheets with nanoporous structure shows the (110) facet (see Fig. 1(f)). On the other hand, the macroscopical color of TiO$_2$ (B) powder changes from white (as-prepared) to light yellow (plasma treated), as shown in the insets of Fig. 1(c) and 1(e), indicating the change of the optical response in the visible light region due to structure variation of energy level.

The optical character of the TiO$_2$ (B) nanosheets was studied by using UV-vis diffuse reflectance absorption spectroscopy (see Fig. 2(a)). The plasma treatment significantly widens the spectral absorption of TiO$_2$ (B), which extends into the visible light region from 400 nm to 770 nm. The band gap values of the samples (inset Fig. 2(a)) can be derived according to the Kubelka-Munk function [23, 24]. The band gap value of the pristine TiO$_2$ (B) nanosheets was approximately 3.13 eV, which is higher than that of plasma one (2.88 eV). Moreover, according to the valence band (VB) XPS spectra (Fig. 2(b)), the estimated band edge positions of the plasma treated TiO$_2$ (B) samples is 2.05 eV, which is lower than that of the pristine (2.95 eV). Based on UV-vis and XPS results, the energy band structure of TiO$_2$ (B) samples could be confirmed and expressed clearly in Fig. 2(c). The conduct band minimum (CBM) of the pristine TiO$_2$ (B) was slightly closer to the $E$ ($\text{H}^*/\text{H}_2$) than that of plasma treated one. It is worth noting that plasma treatment can promote the formation of defect states (marked with red line) in TiO$_2$ (B) and the defect level was below the original CBM [25]. The formation of defect state is mainly due to the introducing of oxygen vacancy, which boards the CBM position to produce the CB tail [26]. The CB tail
could be understood vacancy defect of localized states and the position of defect states locate below the CBM at 0.7-1.0 eV [27]. As mentioned-above, the plasma treatment was used as an effective route to decrease the band gap of TiO$_2$ (B) and promote the formation of defect state, both of which can improve the TiO$_2$ (B) absorption of visible light successfully.

Fig. 2(d) shows the Raman spectra of the pristine and plasma treated TiO$_2$ (B). The peaks of both samples are basically matched to the Raman modes at 146, 196, 245, 400, 513, 635 and 858 cm$^{-1}$ of pure TiO$_2$ (B) phase [28, 29]. However, the peak intensity and peak width of plasma treated TiO$_2$ (B) is lower and broader than that of pristine TiO$_2$ (B), respectively. This is because the plasma treatment seriously influence molecular vibrations of surface crystallinity and break down the Raman scattering selection rules [30, 31]. In addition, the slight blue-shift of pristine TiO$_2$ (B) bands around 149 cm$^{-1}$, 205 cm$^{-1}$ and 258 cm$^{-1}$ are induced by surface strain. These bands are associated with Ti-O-Ti and O-Ti-O in torsional and bending modes, which would automatically resonate with the porous structure and partial crystalline area by energetic plasma particle (see the TEM image 1e) [13, 32, 33]. Furrier transform infrared (FTIR) spectra are shown in Fig. S3. Both of TiO$_2$ (B) exhibit strong absorption at 3400 cm$^{-1}$ and 1630 cm$^{-1}$, which are assigned to O-H surface hydroxyl groups and H-O-H physically adsorbed water, respectively. The large absorption band below 1000 cm$^{-1}$ is referred to Ti-O-Ti stretching vibration of the interconnected octahedral [TiO$_6$] [24, 34]. Contrasting with two FTIR curves, the functional group peaks appears decreasing with different degree after plasma treatment. The functional
group of Ti-O-C, C-C, -CH₂ have mostly removed due to the effect of plasma surface engraving and cleaning [32, 35, 36]. The results proved that the adsorbing contaminant of organic molecule on the surface of TiO₂ (B) nanosheets has been cleared.

We employed XPS to further investigate the chemical compositions and defects of the TiO₂ (B). Fig. S4 (a) shows the full XPS spectra and the high-resolution spectra of Ti 2p, O 1s and C 1s orbits are shown in Fig. 2(e), 2(f) and S4(b), respectively. Ti 2p3/2 and Ti 2p1/2 peaks located at 458.4 eV and 464.1 eV are assigned to the typical Ti⁴⁺ characteristics. The Ti³⁺ is confirmed by the peaks at 457.5 eV, 463.2 eV of pristine TiO₂ and 457.7 eV, 463.8 eV of the plasma-treated one. The Ti³⁺ species are the result of the Ti⁴⁺ reduction of TiO₂ (B) with the plasma treatment, which can be confirmed by the impairing of peak intensity at Ti⁴⁺ 464.1 eV [8, 37]. As shown in Fig. 2(f), O 1s peak derives from four oxygen peaks for both samples. The peaks around 529.8 eV, 531 eV and 533.2 eV are assigned to metal-oxygen bonds of the typical O-Ti-O, surface hydroxyl oxygen (-OH), and adsorption oxygen groups, respectively [38, 39]. A well-resolved O peak at 532 eV can be attributed to the high binding energy peak of defect oxygen [26]. The calculated peak area of defect oxygen of the plasma-treated TiO₂ (B) is 2.2 times as large as that of pristine one, indicating that there are more oxygen defects have been generated in plasma treated TiO₂ (B). Many defects of Ti³⁺ and oxygen vacancies in the plasma treated TiO₂ (B) is able to change the coordination number of Ti-O-Ti, surface lattice structure, and further form a defect state [19, 26]. Compare with pristine TiO₂ (B), Ti³⁺ and vacancy oxygen in
plasma treated TiO$_2$ (B) lead to a relative low electronegativity and high polarizability [8]. According to the XPS analysis, thermal effect of plasma treatment can accelerate formation of the above-mentioned defects in TiO$_2$ (B). Thus, by using the Kröger-Vink nomenclature, the formation processes of the Ti$^{3+}$ and O vacancy defects can be expressed as [24]:

$$
2\text{O}_\text{O} \xrightarrow{\text{Ar plasma}} \text{O}_\text{O} + 2\text{V}_0^- + 4\text{e} \quad (1)
$$

$$
\text{Ti}_{\text{Ti}} + \text{e} \xrightarrow{\text{Ar plasma}} \text{Ti}_{\text{Ti}}' \quad (2)
$$

$$
2\text{O}_\text{O} + 4\text{Ti}_{\text{Ti}} \xrightarrow{\text{Ar plasma}} \text{Ti}_{\text{Ti}}' + \text{O}_2 + 2\text{V}_0^- + 4\text{e} \quad (3)
$$

where O$_0$, V$_0$, Ti$_{\text{Ti}}$, and Ti$_{\text{Ti}}'$ represent lattice oxygen, oxygen vacancy, lattice titanium, and Ti$^{3+}$ substituting the lattice titanium position, respectively.

The electron paramagnetic resonance (EPR) was used to investigate the content variation of defects and free radicals of TiO$_2$ (B). As shown in Fig. 3(a), the pristine TiO$_2$ (B) does not show any free radical characteristics. However, the plasma-treated TiO$_2$ (B) exhibits an obvious response near g factor of 2.0039, which is a typical characteristic of superoxide radicals attached to the oxygen vacancy sites in the oxide materials [40, 41]. The Ti$^{3+}$ defects are accumulated gradually in the sample and usually accompanied with losing of oxygen [35, 42]. Therefore, there were more super oxidation radicals O$_2^-$ to be detected in the plasma treated TiO$_2$ (B) as shown in Fig. 3(b). With the photocatalytic reactions going on, a lot of excited-state electrons are generated to form O$_2^-$ with dissolved oxygen, and then form highly oxidative OH to oxidize organic sacrificial agent through a series of oxidation reactions [43]. Under
light irradiation, these active species (e.g. $O_2^-$, $OH^-$, or $h^+$) can promote the separation and migration of photoelectrons, and indirectly improve the utilization of photoelectrons during the water splitting [44, 45].

To further evaluate the photocatalytic performances of the corresponding samples, $H_2$ evolution experiments were carried out. The plasma treated TiO$_2$ (B) exhibits higher $H_2$ evolution rate (160 μmol/h) than pristine one (96 μmol/h), as shown in Fig. 4(a). Moreover, $H_2$ production rates of both TiO$_2$ (B) samples are higher than that of P25, as shown in Fig. S5 (a). After four recycles $H_2$ evolution test (each recycle is 6 h), the $H_2$ production rates of plasma treated TiO$_2$ (B) still remain excellent cycle stability, as shown in Fig. 4(b). The transient photocurrent response measurements of the TiO$_2$ (B) samples were carried out with the illumination cycles with an interval of 20 s on/off at potential of 0.6 V (vs. Ag/AgCl electrode). Fig. 4(c) shows that the plasma treated TiO$_2$ (B) exhibits a photo-response current density of 43.7 μA·cm$^{-2}$, which is about 4 times of pristine TiO$_2$ (B) (11.3 μA·cm$^{-2}$). Additionally, the linear sweep voltammetry results also confirm the improvement of photo-response current, as shown in Fig. S5(b). Because of defect introduction of Ti$^{3+}$ and O vacancy, these photoelectric results of the plasma treated TiO$_2$ (B) show a highly efficient charge separation and migration pathway.

The Mott-Schottky measurement was conducted at a frequency of 1 kHz. Fig. 4(d) show that all curves exhibit a positive slope in the plots, indicating the characteristic of n-type semiconductor with electrons as primary carriers. The carrier densities were calculated by using the equation [13]
\[ N_d = \frac{2}{e_0 \varepsilon \varepsilon_0} \left[ \frac{d(1/C^2)}{dV} \right]^{-1} \]  

where \( e_0 \) is the electron charge, \( \varepsilon \) is the dielectric constant of TiO\(_2\) (B), \( \varepsilon_0 \) is the permittivity of vacuum, \( N_0 \) is the donor (electron) density, and \( V \) is the applied bias voltage at the electrode. The carrier densities of the pristine and plasma treated TiO\(_2\) (B) are named as \( N_{d1} \) and \( N_{d2} \), respectively. The ratio of \( N_{d2}/N_{d1} \) was calculated as 12.3. The Mott-Schottky plot of plasma treated TiO\(_2\) (B) with flatter slope demonstrate a better capacitance behavior and higher carrier density than that of pristine TiO\(_2\) (B) \([37, 46]\). The enhancement of carrier density is attributed to the O vacancy defects, which change the band structure and board the area of spectrum absorption. With the effect of more carriers, the plasma treated sample could promote the dissociation of molecular adsorption, such as O\(_2\), H\(_2\)O, and CH\(_3\)OH \([18]\). Furthermore, these O vacancies are capable of suppressing charge recombination and leaving many charge carriers to form reactive species for efficient hydrogen production \([18, 46]\).

Herein, introducing defects of Ti\(^{3+}\) and O vacancies in TiO\(_2\) (B) through a plasma engraving strategy can improve their photoexcitation activity and accelerate the H\(_2\) production. Because of the destruction of O-Ti-O, Ti-O-Ti bonds by the plasma bombard, the residual electrons can migrate from lattice Ti and O atom and then create the defective lattice structure of TiO\(_2\) (B) \([13, 34]\). The characteristic electronic and defective structures enable the plasma treated TiO\(_2\) (B) to have unique physical and chemical properties, which include the favored visible light absorption, dissociative adsorption, and reductive properties. Due to the mixing of engraving defects, it caused obviously energy band changing of TiO\(_2\) (B), including the
appearance of defect state and upper shift of VBM location. It could not only effectively promote absorption of visible light region, but also further decrease transition energy of carriers. Meanwhile, the O vacancies in the TiO$_2$ (B) will facilitate the dissociative adsorption of the reactant molecule and modify the further reactions at a molecular level. The plasma treated TiO$_2$ (B) have larger specific surface area and more active sites, which can be considered as reactive acceptors for corresponding reactions, such as the reduction of H$^+$, oxidation of organic molecule, adsorption and dissolving of water molecule. Moreover, plasma engraving structure of TiO$_2$ (B) promotes photocatalytic efficiency of photo-induced hole with methanol hole-scavengers which depresses charge recombination of photo-induced carriers and facilities the transfer of electrons into H$^+$/H$_2$O [47, 48]. Overall, the plasma treated TiO$_2$ (B) nanosheets can enhance the reaction efficiency of photocatalytic water splitting.

4. Conclusion

In summary, this study demonstrated that plasma treatment could be an effective method to improve the photocatalytic performance of TiO$_2$ (B) nanosheets. The plasma treated TiO$_2$ (B) with defects Ti$^{3+}$ and O vacancy performed standard advantages over pristine TiO$_2$ (B) nanosheets in production of H$_2$ under full spectrum light. The engraving effect of plasma generated porous structure on pristine TiO$_2$ (B) nanosheets and increased specific surface area apparently. The more exposed surface area with O vacancies defects would facilitate the dissociative adsorption of the reactant molecule and promote the reaction efficiency. The insert defect state below
the conduction band minimum shortened the width of original band gap and significantly extended the optical absorption spectrum of TiO$_2$ (B) to the visible region. It is believed that this approach would be feasible and promising to apply in other photocatalysts for solar energy utilization and water splitting hydrogen energy in future.

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References


**Figure captions**

Scheme 1. Preparation routes of plasma-treated TiO$_2$ (B).
Fig.1. (a) XRD patterns for the pristine TiO$_2$ (B) and plasma-treated TiO$_2$ (B) nanosheets, (b) nitrogen sorption isotherm of the pristine and plasma-treated TiO$_2$ (B) nanosheets, (c-d) the TEM images, high-resolution TEM of the pristine TiO$_2$ (B), the insets in Fig. 1 (c) and (d) is digital picture and SAED pattern of TiO$_2$ (B), respectively, (e-f) the TEM images, high-resolution TEM of the plasma treated TiO$_2$ (B), the insets in Fig. 1 (e) and (f) is digital picture and SAED pattern of plasma treated TiO$_2$ (B), respectively.
Fig. 2. (a) UV-visible absorption spectra DRS, the insets in Fig. 2 (a) is the corresponding plots of transformed Kubelka-Munk function versus the energy of photon, (b) XPS valence band spectra, (c) schematic illustration of the energy band structures of pristine and plasma treated TiO$_2$ (B), (d) Raman spectra of the pristine and plasma-treated TiO$_2$ (B), (e-f) XPS spectra of Ti 2p peaks and O 1s peaks for the pristine and plasma-treated TiO$_2$ (B), respectively.
Fig.3. (a) EPR spectra and (b) DMPO-O$_2^-$ adduct radical (●) and nitroxide-like radical (◆) spectra for the pristine TiO$_2$ (B) and plasma-treated TiO$_2$ (B) nanosheets.

Fig.4. (a) The photocatalytic properties of H$_2$ production, (b) the recyclability of H$_2$ production, (c) transient photocurrent response tests, and (d) Mott-Schottky analysis for the pristine TiO$_2$ (B) and plasma-treated TiO$_2$ (B) nanosheets.
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